

XA-9693A

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

Yoshitaka SASAGO et al.

Appln. No.:

Filed: HERewith

For: NONVOLATILE SEMICONDUCTOR MEMORY DEVICE AND
MANUFACTURING METHOD THEREOF

* * *

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

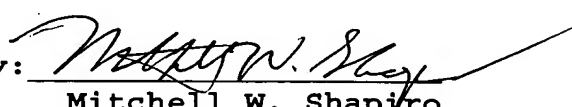
Applicants wish to make of record the documents cited in
prior Application No. 10/166,145 filed June 11, 2002, whether
cited by Applicants or by the Patent Office. The documents
are listed on the attached Form PTO-1449.

Respectfully submitted,

MWS:lmb

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November 6, 2003

By:


Mitchell W. Shapiro
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FORM PTO-1449				Atty. Docket No. XA-9693A		Appln. No.	
<u>LIST OF DOCUMENTS CITED BY APPLICANT</u>							
				Applicant Yoshitaka SASAGO et al.			
				Filing Date HEREWITH		Group	
U.S. PATENT DOCUMENTS							
Examiner Initial		Document Number	Date	Name	Class	Sub-class	Filing Date
	AA	5,095,344	03/10/92	Harari (corrs. to JP 2694618)	357	23.5	
	AB	5,739,569	4/98	Chen	257	322	
	AC	5,773,863	6/98	Burr et al.	257	316	
	AD	6,492,690	12/02	Ueno et al.	257	316	
	AE	4,561,004	12/85	Kuo et al.	257	319	
	AF	4,745,083	5/88	Huie	257	316	
	AG	5,455,792	10/95	Yi	257	345	
	AH	5,640,032	6/97	Tomiooka	257	316	
	AI						
FOREIGN PATENT DOCUMENTS							
Examiner Initial		Document Number	Date	Country	Class	Sub-class	Translation
	AJ	2694618	09/12/97	Japan			No
	AK	9-321157	12/12/97	Japan			Abstract
	AL						
	AM						
	AN						
	AO						
OTHER (including author, title, date, pertinent pages, etc.)							
	AP	"Ohyo Butsuri" (or APPLIED PHYSICS), The Japan Society of Applied Physics, Vol. 65, No. 11, November 10, 1996, pp. 1114-1124.					
	AQ	K. Naruke et al., "A New Flash-Erase EEPROM Cell with a Sidewall Select-Gate on its Source Side", IEDM, 1989, pp. 603-606.					
	AR						
Examiner				Date Considered			
EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.							